Pulsed DC System Update

23rd June 2022

$$\frac{1}{R^*} = \frac{1}{R_{\text{osc}}} + \frac{1}{R_1} + \frac{1}{R_2} = \frac{1}{1E6} + \frac{1}{R1} + \frac{1}{1E7}$$

$$R_1 = 1E5 \therefore R^* = 90.09k\Omega$$

$$R_2 = 1E7 \therefore R^* = 833.333k\Omega$$

If the resistance of the gap is 0 then the voltage \bigvee potential on the ground of the chamber is:

$$= \frac{V}{R + R^*} \times R^*$$

$$= \frac{V}{6.36E6 + R^*} \times R^*$$

For V=10kV

$$R_1 = 1E5 : R^* = 139.67V$$

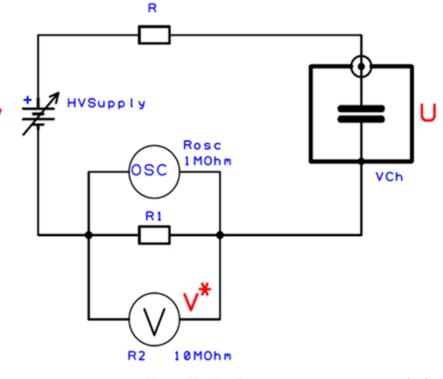
 $R_2 = 1E7 : R^* = 1158V$

For V=6kV

$$R_1 = 1E5 : V^* = 83.8V$$

 $R_2 = 1E7 : V^* = 695V$

The voltage is displayed on the multi-meter and for safety should definitely not exceed 120V DC during field emission measurements. It is never safe to touch the chamber as a BD could happen. Safe distance for Low Voltage (120V-1500V DC) is 30cm.



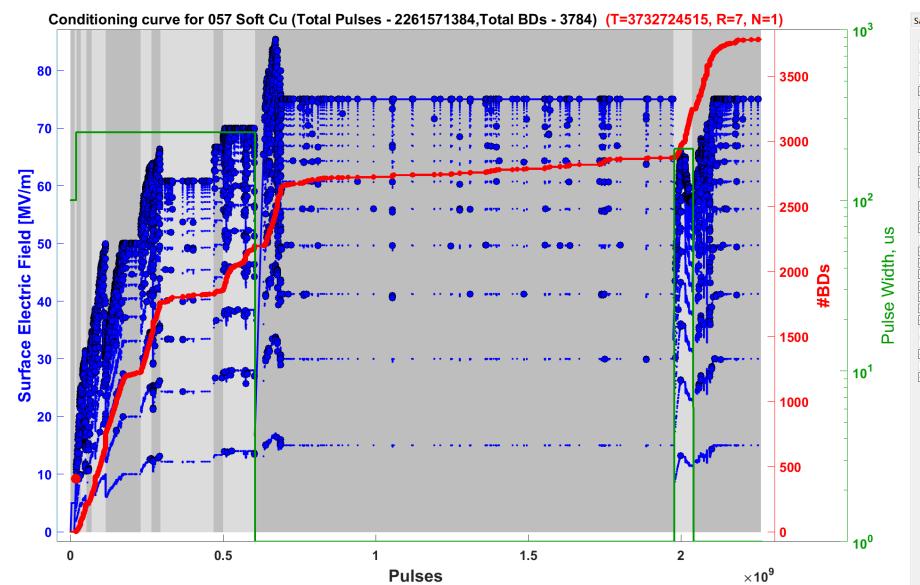
$$U = V - I \times R \tag{5.1}$$

$$I = V^*/R^* (5.2)$$

$$1/R^* = 1/R_{osc} + 1/R_1 + 1/R_2 (5.3)$$

Where U = gap voltage, V = supplied voltage, I = field emission current, V* = multi-meter voltage, R* = gap resistance, R = series resistance = $6.36\mathrm{M}\Omega$, $R_1 = 100k\Omega, 1M\Omega, or 10M\Omega$, therefore $R_{osc} = 1M\Omega$ = oscilloscope resistance, $R_2 = 10M\Omega$ = multi-meter resistance.

Soft Cu Conditioning



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